

**Application Data Sheet****Application Information**

Application Type::	Regular
Subject Matter::	Utility
CD-ROM or CD-R:	None
Title::	METHOD OF PRODUCING PHASE SHIFT MASK BLANK, METHOD OF PRODUCING PHASE SHIFT MASK, PHASE SHIFT MASK BLANK, AND PHASE SHIFT MASK
Attorney Docket Number::	119162
Total Drawing Sheets::	15
Small Entity::	No

**Applicant Information**

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Hiroki
Family Name::	YOSHIKAWA
City of Residence::	Niigata
Country of Residence::	Japan

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Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Yukio
Family Name::	INAZUKI
City of Residence::	Niigata
Country of Residence::	Japan

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Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan

Status:: Full Capacity  
 Given Name:: Noriyasu  
 Family Name:: FUKUSHIMA  
 City of Residence:: Niigata  
 Country of Residence:: Japan

Applicant Authority type:: Inventor  
 Primary Citizenship Country:: Japan  
 Status:: Full Capacity  
 Given Name:: Hideo  
 Family Name:: KANEKO  
 City of Residence:: Niigata  
 Country of Residence:: Japan

Applicant Authority type:: Inventor  
 Primary Citizenship Country:: Japan  
 Status:: Full Capacity  
 Given Name:: Satoshi  
 Family Name:: OKAZAKI  
 City of Residence:: Niigata  
 Country of Residence:: Japan

### Correspondence Information

Correspondence Customer Number:: 25944

Foreign Priority Information			
Country::	Application Number::	Filing Date::	Priority Claimed::
Japan	2003-093280	03/31/2003	Yes
Country::	Application Number::	Filing Date::	Priority Claimed::
Japan	2003-093296	03/31/2003	Yes
Country::	Application Number::	Filing Date::	Priority Claimed::
Japan	2003-093301	03/31/2003	Yes
Assignee Information			
Assignee Name::	Shin-Etsu Chemical Co., Ltd.		
Street of mailing address::	6-1, Ohtemachi 2-chome, Chiyoda-ku		
City of mailing address::	Tokyo		
Country of mailing address::	Japan		